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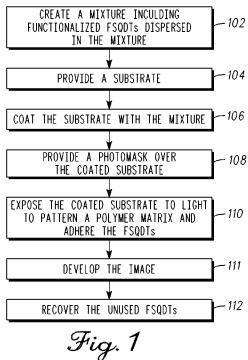
US

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[Continued on next page]

(54) Title: METHOD AND APPARATUS FOR SELECTIVELY PATTERNING FREE STANDING QUANTOM DOT (FSQDT) POLYMER COMPOSITES



(57) Abstract: Free standing quantum do (FSQDT) polymer composites and a method and apparatus for patterning the FSQDT polymer composites is provided. The method for patterning the FSQDT polymer composites includes creating a solution including FSQDTs (102) where each of the FSQDTs has a plurality of reactive ligands chemically attached thereto. The method further includes providing a substrate (104), forming a coated substrate by coating a surface of the substrate with a layer of the solution (106), and providing a photo mask having a predetermined pattern thereon transparent to a predetermined radiation over the coated substrate (108). Finally, the method includes exposing a portion of the coated substrate to the predetermined radiation passing through the mask to pattern a polymer matrix in the predetermined pattern while adhering the FSQDTs to the polymer matrix (110) to form the FSQDT polymer composite.

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A. CLASSIFICATION OF SUBJECT MATTER

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According to International Patent Classification (IPC) or to both national classification and IPC

B. FIELDS SEARCHED

Minimum documentation searched (classification system followed by classification symbols)

IPC8 H01L 21/027, G03F 7/00, H01L 21/20, H01L 21/31

Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched Korean Utility models and applications for Utility models since 1975

Japanese Utility models and applications for Utility models since 1975

Electronic data base consulted during the international search (name of data base and, where practicable, search terms used) eKIPASS(KIPO internal) "quantum dot, mixture, pattern"

C. DOCUMENTS CONSIDERED TO BE RELEVANT

Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No
X Y	KR 10-2006-0103356 A (SEOUL NATIONAL UNIVERSITY INDUSTRY FOUNDATION) 29 September 2006 See abstract, figs. 1-3, page 2, claims 1 and 3	55-68 1-54,69-73
Y	KR 10-2005-0003548 A (SAMSUNG ELECTRONICS CO., LTD.) 12 January 2005 See abstract, pages 2-9, claims 1-3 and 6-7	1-73
Y	US 2007-032091 A1 (HEALD, D. L. et al.) 08 February 2007 See abstract, figs. 2 and 10, paras. [0078]-[0084], claims 1-2 and 11	1-73
Y	KR 10-2006-0086128 A (SAMSUNG ELECTRONICS CO., LTD.) 31 July 2006 See abstract, claims 1,6-8,10,13, and 15-16	1-73

Further documents are listed in the continuation of Box C.	See patent family annex.		
* Special categories of cited documents: "A" document defining the general state of the art which is not considered	"T" later document published after the international filing date or priority date and not in conflict with the application but cited to understand		
to be of particular relevance	the principle or theory underlying the invention		
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INTERNATIONAL SEARCH REPORT

Information on patent family members

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	Patent document cited in search report	Publication date	Patent family member(s)	Publication date
	KR 10-2006-0103356 A	29.09.2006	None	
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